Stress tuning of membrane resonators through on-chip heating

J. Dornseiff¹, M. Fu¹, F. Yang¹, E. Scheer¹

¹Fachbereich Physik, Universität Konstanz, D-78457 Konstanz, Germany

The nonlinearity of micro-electro-mechanical systems (MEMS) has gathered great interest for research as well as many engineering applications, like signal processing [1] and amplification [2], mass sensing [3], displacement measurement [4] and more. The nonlinear- ity is inherent to the MEMS, but it can be tuned by heating the device [5]. Additionally the shift in the eigenfrequency during a tem- perature change can be precicely observed in the linear regime, allowing for applications as temperature sensors [6].

Here we demonstrate the shift in eigenfrequency, by increasing the temperature with a resistive on-chip heating structure around a silicon nitride membrane and observe its nonlinear behavior with changing temperature via imaging white light interferometry.

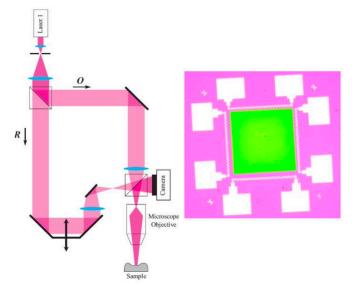


Fig. 1: Simplified optical principle of an IWLI and the Au/Ti heater set-up around the membrane.

References:

- [1] Erbe A et al, Appl. Phys. Lett. 77 3102-4 (2000)
- [2] Almog R et al, Appl. Phys. Lett. 88 213509 (2006)
- [3] Buks E and Yurke B, Phys. Rev. E 74 046619 (2006)
- [4] Trusov A and Shkel A J. Micromech. Microeng. 17 1583-92 (2007)
- [5] Suo J et al J. Phys.: Condens. Matter 34 374004 (2022).
- [6] Yang F et al Appl. arXiv 1704.05328v2 (2017).